

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

1. (previously presented) A method for manufacturing a lithographic printing plate, the method comprising:

conveying a support, on which a photosensitive coating solution containing an organic solvent is coated such that a photosensitive coated layer is formed by the photosensitive coating solution;

drying the photosensitive coated layer by a first heating means to a dry-to-touch state;

heating the support and the photosensitive coated layer by a second heating means, which does not contact the support and the photosensitive coated layer, and which is provided at a downstream side of the first heating means, so that hardening of the photosensitive coated layer is promoted; and

changing a condition of heating of the second heating means while the support is being conveyed.

2. (previously presented) A method for manufacturing a lithographic printing plate according to claim 1, wherein the first heating means heats the photosensitive coated layer to 90°C or more.

3. (previously presented) A method for manufacturing a lithographic printing plate according to claim 1, wherein the first heating means dries the photosensitive coated layer such that a remaining amount of the organic solvent in the photosensitive coated layer is 5 wt% or less of the photosensitive coated layer.

4. (canceled).

5. (original) A method for manufacturing a lithographic printing plate according to claim 1, wherein a heating system of the second heating means is a heat radiation system.

6. (original) A method for manufacturing a lithographic printing plate according to claim 1, wherein a heating system of the second heating means is an induction heating system.

Claims 7-8. (canceled).

9. (previously presented): A method for manufacturing a lithographic printing plate according to claim 1, wherein the condition of heating by the second heating means is controlled in accordance with a type of the photosensitive coated layer formed on the support, such that a temperature of the photosensitive coated layer immediately after heating by the second heating means is a predetermined temperature which is set in accordance with the type of the photosensitive coated layer.

Claims 10-11. (canceled).

12. (previously presented): A method for manufacturing a lithographic printing plate, the method comprising:

supplying a plurality of supports that have different thicknesses or widths, the supports being coated with a photosensitive coating solution containing an organic solvent such that photosensitive coated layers are respectively formed by the photosensitive coating solution, the supports being connected together;

drying the photosensitive coated layers by a first heating means to a dry-to-touch state;

heating the supports and the photosensitive coated layers by a second heating means provided at a downstream side of the first heating means so that hardening of the photosensitive coated layers is promoted; and

changing a condition of heating the supports and the photosensitive coated layers by the second heating means in accordance with thicknesses or widths of the supports.

13. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, wherein the second heating means is a plurality of drying devices which are disposed along a conveying path of the supports, and amounts of heat supplied by the plurality of heating devices are respectively controlled in accordance with changes in dimensions of the supports.

AMENDMENT UNDER 37 C.F.R. § 1.116
U.S. Patent Application No. 09/895,264

14. (original): A method for manufacturing a lithographic printing plate according to claim 1, wherein after hot air drying of the coated layer by the first heating means, the second heating means radiates mid-infrared radiation or far infrared radiation to the photosensitive coated layer and the support so as to heat the support and the photosensitive coated layer.

Claims 15-16. (canceled).

17. (previously presented): A method for manufacturing a lithographic printing plate according to claim 1, further comprising forming an overcoat layer on the photosensitive coated layer.

18. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, wherein the first heating means heats the photosensitive coated layers to 90°C or more.

19. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, wherein the first heating means dries the photosensitive coated layers such that a remaining amount of the organic solvent in the photosensitive coated layers is 5 wt% or less of the photosensitive coated layers.

AMENDMENT UNDER 37 C.F.R. § 1.116
U.S. Patent Application No. 09/895,264

20. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, wherein a heating system of the second heating means is a heat radiation system.

21. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, wherein a heating system of the second heating means is an induction heating system.

22. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, wherein the condition of heating by the second heating means is controlled in accordance with a type of the photosensitive coated layers formed on the supports, such that a temperature of the photosensitive coated layers immediately after heating by the second heating means is a predetermined temperature which is set in accordance with the type of the photosensitive coated layers.

Claim 23 (canceled).

24. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, wherein after hot air drying of the photosensitive coated layers by the first heating means, the second heating means radiates mid-infrared radiation or far infrared radiation to the photosensitive coated layers and the supports so as to heat the supports and the photosensitive coated layers.

25. (previously presented): A method for manufacturing a lithographic printing plate according to claim 12, further comprising forming overcoat layers on the photosensitive coated layers.

26. (canceled).

27. (currently amended): A method for manufacturing a lithographic printing plate according to claim [[26]] 1, wherein the condition of heating of the second heating means is changed while the support is being conveyed based on a detected temperature of the photosensitive coated layer while the support is being conveyed.

28. (currently amended) A method of manufacturing a lithographic printing plate according to claim [[26]] 1, wherein the condition of heating of the second heating means is changed while the support is being conveyed based on a detected temperature of the support after drying the photosensitive coated layer by the first heating means and a detected temperature of the support after heating the support and the photosensitive coated layer by the second heating means.

29. (currently amended) A method of manufacturing a lithographic printing plate according to claim [[26]] 1, wherein the condition of heating of the second heating means is changed while the support is being conveyed based on a detected change in width of the support.